## APPENDIX A

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of: Docket No.: 020732-97.668 (7493)Applicants: RATH, Melissa K., et al. Conf. No.: 4823 Application No.: 10/792,038 Art Unit: 1752 Date Filed: March 3, 2004 Examiner: LE, Hoa Van Title: COMPOSITION AND PROCESS FOR Customer No.: 24239 POST-ETCH REMOVAL OF PHOTORESIST AND/OR SACRIFICIAL ANTI-REFLECTIVE MATERIAL DEPOSITED ON A SUBSTRATE

## DECLARATION UNDER 37 CFR §1.131 IN U.S. PATENT APPLICATION NO. 10/792,038

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir

MELISSA K. RATH, DAVID D. BERNHARD, DAVID W. MINSEK, MICHAEL B. KORZENSKI, and THOMAS H. BAUM hereby declared

- THAT we are co-inventors of the subject matter disclosed and elected in United States
  Patent Application No. 10/792,038 filed March 3, 2004 in the names of Melissa K. 11th,
  David D. Bernhard, David W. Minsek, Michael B. Korzenski, and Thomas H. Baum and
  entitled, "COMPOSITION AND PROCESS FOR POST-ETCH REMOVAL OF
  PHOTORESIST AND/OR SACRIFICIAL ANTI-REFLECTIVE MATERIAL
  DEPOSITED ON A SUBSTRATE," hereafter referred to as the "Application."
- THAT the Application relates to compositions and processes for removing photoresist
  and/or sacrificial anti-reflective coating (SARC) from a substrate having said meterials
  thereon. The elected claims specifically relate to the following composition:

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- A cleaning composition including an active cleaning combination (ACC), wherein said ACC consists of a quaternary base in combination with at least one of alkali and alkaline earth base and said cleaning composition is useful for removing photoresist and/or sacrificial anti-reflective coating (SARC) materials from a substrate having such material(s) thereon.
- 3. THAT we are aware that the Application has been examined by the United States Patent and Trademark Office and the claims of the Application have been rejected on various grounds including the disclosure of:
  - Yokoi, et al. (U.S. Patent Application Publication No. 2004/0259761) (hereinafter "the Yokoi reference") filed on June 10, 2004, based on U.S. Provisional Application No. 60/479,146, filed June 18, 2003, the content of which is unknown because it was filed in Japanese (hereinafter "the Yokoi Provisional Application").
  - 3. THAT Exhibit A attached herewith includes true and exact copies of pages of David D. Bernhard's and Melissa K. Rath's laboratory notebooks, and that all concepts, experiments and acts disclosed on the laboratory notebook pages were conducted in the United States before the filing date of the Yokoi Provisional Application cited bereinabove.
  - 4. THAT all the dates have been blacked out on the attached laboratory notebook pages but all dates are prior to the date of June 18, 2003, which is the filling date of the Yokni Provisional Applications<sup>2</sup> that information on the laboratory notebook pages that may not be in the public domain has been reducted; and that every one of the stached laboratory notebook pages (Appendix A) discloses a composition including an active cleaning composition (ACC), wherein said ACC consists of a quaternary base in combination with at least one of alkali and alkaline earth base. Thus, the combination of disclosures described herein, provides ample support for the presently claimed invention.
  - 5. THAT we offer Exhibit A with this Declaration as evidence of the completion and possession of the cleaning compositions disclosed and claimed in the Application prior to the June 18, 2003 date of the Yokoi Provisional Application reference.

Melissa K. Murphy has reassumed her maiden name "Rath"

<sup>&</sup>lt;sup>2</sup> assuming that the Yokoi Provisional Application enables the Yokoi reference.

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THOMASH BAUM

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As a below-named declarant, I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements are made with the knowledge that willful false statements, and the like, so made are punishable by fine or imprisonment, or both, under Section 1001 or Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

Melin K. R.R.	Dato8/14/06
MELISSA K, RATH	
	Date
DAVID D, BERNHARD	
David Mingel	Date 8/14/06
DAVID W. MINSEK	. 1 '
Mill & /get	Date 8/14/06
MICHAEL B. KORZENSKI	, , ,
Thomas # Baun	Date 8-14-06

As a below-named declarant, I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements are made with the knowledge that willful false statements, and the like, so made are punishable by fine or imprisonment, or both, under Section 1001 or Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

	Date
MELISSAK. RATH	Date 8/15/06
DAVID D. BERNHARD	
DAVID W. MINSEK	Date
UAVID W. MILIOZIK	
MICHAEL B. KORZENSKI	Date
	Date
THOMAS H. BAUM	

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EXHIBIT A





